

**PROCESS FOR DEPOSITING BTBAS-BASED SILICON NITRIDE FILMS**

Appl. No. : 10/711,414 Confirmation No. 5413  
Applicant : Yun-Ren Wang,  
                 Ying-Wei Yen,  
                 Hao-Hsiang Chang,  
                 Tsai-Fu Hsiao  
Filed : September 17, 2004  
TC/A.U. : 1709  
Examiner : MILLER, MICHAEL G  
Docket No. : NAUP0594USA  
Customer No. : 27765

Commissioner for Patents

P.O. Box 1450

Alexandria VA 22313-1450

**AMENDMENT**

Sir:

In response to the Office action of June 29, 2007, please amend the above-identified  
5 application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Amendments to the Drawings** begin on page 4 of this paper and include an attached replacement sheet showing changes.

10 **Remarks/Arguments** begin on page 5 of this paper.

An **Appendix** including the amended drawing figure is attached following page 9 of this paper.